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PATENT  
Customer No. 22,852  
Attorney Docket No. 1197-226

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: )  
)  
Shinji Aki et al. ) Group Art Unit: Not Yet Assigned  
)  
Application No.: 09/869,264 ) Examiner: Not Yet Assigned  
)  
Filed: June 27, 2001 )  
)  
For: Process for Producing Carbostyryl )  
Derivatives )  
)

Assistant Commissioner for Patents  
Washington, DC 20231

Sir:

**PRELIMINARY AMENDMENT**

Prior to the examination of the above application, please amend this application as follows:

**IN THE SPECIFICATION:**

Page 3, replace the paragraph beginning on line 2 with the following new paragraph:

According to the above-mentioned known process, the yield of the compound of general formula (I) is as low as about 50 to 74%, because there is also formed a compound in which the tetrazole derivative of general formula (III') has reacted not only with the hydroxyl group of the carbostyryl derivative of general formula (II) but also with the 1-position of the carbostyryl derivative of general formula (I) simultaneously. Since the thus formed contaminative impurity is difficult to remove, production of a compound of general formula (I) having a high purity has required a complicated process of purification.

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